



SEMICONDUCTOR PROPERTIES

	Lattice Constant a _o (Å)	Energy Gap E _g (eV)	Mobility @ 300K (cm ² /V sec)	
			Electrons	Holes
Si	5.4310	1.11	1400	470
Ge	5.6461	0.67	3900	1900
GaP	5.4506	2.26	110	75
AlP	5.4625	2.45		
GaAs	5.6535	1.42	8500	400
AlAs	5.6605	2.17	280	
InP	5.8688	1.35	5000	150
InAs	6.0584	0.36	33000	460
GaSb	6.0954	0.72	5000	850
AlSb	6.1355	1.58	900	450
InSb	6.4788	0.17	80000	1250
ZnSe	5.6676	2.80	530	
ZnTe	6.0880	2.20	530	130
CdTe	6.4816	1.49	700	60

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The family tree of III-V and II-VI compound semiconductors has a wide range of lattice constants and a correspondingly broad spectrum of bandgap energies. The horizontal rainbow depicts visible transitions available in materials with large energy gaps (trending to small lattice constants) while tie lines indicate the properties of pseudobinary compounds formed from the end point compounds. Discontinuous slopes in these tie lines correspond to band crossovers from indirect to direct. Some tie lines are straight, usually indicating ignorance of "bowing parameters." Graphics by K. Rice and M. Youngman, Sandia National Laboratories. (Previously unpublished.)

The MRS Bulletin's Facts and Figures department presents graphs, nomographs, tables, charts, and frequently used information of the type compiled by materials researchers and often taped to the walls by their desks. These "cheat sheets" are intended to be not only interesting but useful enough to keep for reference. Please send your comments and any potential material for future publication to: Alan Hurd (ajhurd@sandia.gov), Sandia National Laboratories, Albuquerque, NM 87185-0609.

New Materials Development

New Characterization Methods New Process Technology

ABSTRACT DEADLINE: JUNE 20, 1994

TECHNICAL PROGRAM

- A: Beam-Solid Interactions for Materials Synthesis and Characterization
- B1: Evolution of Thin-Film and Surface Structure and Morphology
- B2: Thin Films Stresses and Mechanical Properties V
- C: Structure and Properties of Interfaces in Ceramics
- D: Atomic Level Control of Epitaxial Heterostructures
- E: Chemical Perspectives of Microelectronics Materials IV
- F: Microcrystalline & Nanocrystalline Semiconductors
- G: Science and Technology of Fullerene Materials
- H: High Tc Superconductivity Materials and Applications
- I1: Materials for Smart Systems
- 12: Ferroelectric Thin Films IV
- Ja: Engineering of Nanostructured Materials
- Jb: Grain Size and Mechanical Properties Fundamentals and Applications
- K: Chemical Vapor Deposition of Refractory Metals and Ceramics III
- L: High Temperature Ordered Intermetallic Alloys VI
- M: Ceramic Matrix Composites Advanced High-Temperature Structural Materials
- N: Dynamics in Small Confining Systems II
- Oa: Computational Approaches and Applications to Predicting Properties of Complex Materials
- Ob: Applications of Innovative Knowledge Bases in Materials Design
- P: Fractal Aspects of Materials
- Q: Characterization and Properties of Defects in Polymer Materials
- R: Polymer Matrix Composites
- S: Biomolecular and Biomimetic Materials
- T: Synthesis and Properties of Advanced Catalytic Materials
- U: Solid State Ionics IV
- Va: Microstructure of Cement-Based Systems
- Vb: Bonding and Interfaces in Cementitious Materials
- W1: Advances in Porous Materials
- W2: Hollow and Solid Spheres and Microspheres Science and Technology Associated With Their Fabrication and Application
- X: Frontiers of Materials Research
- Y: Microstructure of Irradiated Materials
- Za: Optical Waveguide Materials
- Zb: Materials for Optical Limiting
- AA: Applications of Synchrotron Radiation Techniques to Materials Science II
- BB: Neutron Scattering in Materials Science II



November 28 - December 2, 1994 Boston Marriott Hotel and Westin Hotel/Copley Place Sheraton Boston Hotel Boston, Massachusetts

SHORT COURSE PROGRAM

The Materials Research Society is offering its outstanding Short Course and Tutorial Program at the 1994 Fall Meeting. Up-to-date courses on the latest advances in the materials sciences and engineering complement the Fall Meeting symposium topics. Designed with something for everyone in research, development or processing of materials, the courses include overview presentations, in-depth instruction in specialty and emerging areas, and practical discussions for problem solving, all taught by instructors who are experts in their fields. Class sizes are limited. Early preregistration is encouraged.

EXHIBIT AND TABLE-TOP DISPLAY

An MRS exhibit and table-top display at the 1994 Fall Meeting will be located convenient to the technical session rooms. Features include the latest analytical and processing equipment, and publications, which closely parallel the nature of the technical symposia. For information, contact Mary E. Kaufold, Manager, Advertising and Exhibits, Materials Research Society, 9800 McKnight Road, Pittsburgh, PA 15237-6006 ; Telephone (412) 367-3036, Fax (412) 367-4373.

PROCEEDINGS

Many symposia from this meeting will publish proceedings. MRS members and meeting attendees may purchase copies of these proceedings at special prepublication prices and receive priority shipment upon publication. Prices will be higher following the meeting. To take advantage of these special prices, order your proceedings while registering for the meeting. For information on nonmember proceedings prices and ordering procedures, contact the MRS Publications Department.

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A Job Placement service for MRS meeting and short course attendees will be open Tuesday through Thursday during the 1994 Fall Meeting.

For specific technical program information, contact any of the 1994 Fall Meeting Chairs:

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For general meeting information, or to request a Call for Papers booklet, a detailed 1994 Fall Meeting program, or information on short courses, publications, exhibit, job placement, or symposium aides, contact:



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The MRS 1994 Fall Meeting will serve as a key forum for discussion of interdisciplinary leading-edge materials research from around the world. Various meeting formats - oral, poster, round-table, forum and workshop sessions - are offered to maximize participation.